

Fig. 1: TEM cross-section showing the stack (quartz / ALD (Al_2O_3) / Deposition ($\sim\text{Al}_2\text{O}_3$)). Copyright © EAG, Inc. including a link to www.eag.com

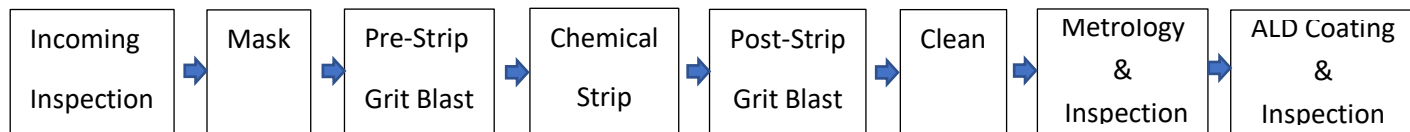


Fig. 2: Process flow for recycling quartz plate

Element	Pre-Clean	Post-Strip and Clean
Si ($\% \pm 2\sigma$)	86.67 \pm 0.52	99.99 \pm 0.00
Al ($\% \pm 2\sigma$)	13.08 \pm 0.17	
V ($\% \pm 2\sigma$)	0.064 \pm 0.01	
Cr ($\% \pm 2\sigma$)	0.18 \pm 0.012	

Fig. 3: XRF results post-strip and clean show no coating nor by-products